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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/048,192	06/03/2002	Manfred Engelhardt	12816-042001	2875	
75	90 03/10/2003				
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			ART UNIT	PAPER NUMBER	
			2812		
		DATE MAILED: 03/10/2003			

Please find below and/or attached an Office communication concerning this application or proceeding.

١		Application No.	Applicant(s)				
Office Action Summary		10/048,192	ENGELHARDT ET AL.				
		Examiner	Art Unit				
		H. Jey Tsai	2812				
	The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply						
A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) FROM THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a reply within the statutory minimum of thirty (30) days will be considered timely. - If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication. - Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). - Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b). Status							
	1) Responsive to communication(s) filed on						
	2a) ☐ This action is FINAL . 2b) ☑ This action is non-final.						
3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213. Disposition of Claims							
4)⊠ Claim(s) <u>1-20</u> is/are pending in the application.							
	4a) Of the above claim(s) is/are withdrawn from consideration.						
5) Claim(s) is/are allowed.							
6)⊠ Claim(s) <u>1-20</u> is/are rejected.							
	7) Claim(s) is/are objected to.						
8) Claim(s) are subject to restriction and/or election requirement.							
Application Papers							
9) The specification is objected to by the Examiner.							
10) The drawing(s) filed on is/are: a) accepted or b) objected to by the Examiner.							
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a). 11) The proposed drawing correction filed on is: a) approved b) disapproved by the Examiner							
11)∐ The proposed drawing correction filed on is: a) ☐ approved b) ☐ disapproved by the Examiner. If approved, corrected drawings are required in reply to this Office action.							
12) The oath or declaration is objected to by the Examiner.							
Priority under 35 U.S.C. §§ 119 and 120							
13) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).							
	a) ☐ All b) ☐ Some * c) ☐ None of:						
	1. Certified copies of the priority documents have been received.						
	2. Certified copies of the priority documents have been received in Application No						
Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received.							
	14) Acknowledgment is made of a claim for domestic priority under 35 U.S.C. § 119(e) (to a provisional application).						
a) The translation of the foreign language provisional application has been received. 15) Acknowledgment is made of a claim for domestic priority under 35 U.S.C. §§ 120 and/or 121.							
Attachment(s)							
2)	Notice of References Cited (PTO-892) Notice of Draftsperson's Patent Drawing Review (PTO-948) Information Disclosure Statement(s) (PTO-1449) Paper No(s) Z.	4) Interview Summary (I 5) Notice of Informal Pa 6) Other:	PTO-413) Paper No(s) tent Application (PTO-152)				
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2) 3) Application/Control Number: 10/048,192

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Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 1-20 are rejected under 35 U.S.C. 103(a) as being unpatentable over Jeng et al. 5,780,338 or Wolstenholme et al. 5,814,527 in view of Huang et al. 5,723,374 and Lien 6,124,165.

The reference(s) teach the features:

Jeng et al. substantially teaches forming a contact hole, comprising:

forming a mask 44 over the upper layer 42, fig. 3+,

etching upper layer 42 and into intermediate layer 40, see col. 6, lines 63⁺,

etching a TEOS or nitride layer 46 and exposing the substrate.

Wolstenholme et al. substantially teaches forming a contact hole, comprising:

forming a mask over the upper layer 230, fig. 9+,

etching upper layer 230 and into intermediate layer 210,

etching a TEOS or oxide layer 270/280 and exposing the substrate.

Huang et al. teaches using ozone (O₃) TEOS or TEOS as a sidewall spacer material 24 in col. 2, lines 60+.

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Lien teaches using polyimide as a photoresist mask 58 in col. 7, lines 61+.

It would have been obvious to one having ordinary skill in the art at the time the invention was made to have modified Jeng or Wolstenholme's process with a ozone TEOS instead TEOS and using polyimide as a photoresist mask as suggested by Huang and Lien because both material are similar and interchangeable.

Any inquiry of a general nature or clerical matters or relating to the status of this application or proceeding should be directed to the Group customer service whose telephone number is (703) 306-3329 and Fax number (703) 308-7722. Group receptionist telephone number 703-308-0956.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to H. Jey Tsai whose telephone number is (703) 308-1374. The examiner can normally be reached on from 7:00 Am to 4:00 Pm., Monday thru Friday.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, John Niebling can be reached on (703) 308-3325. The fax phone number for this Group is (703) 305-3431.

hjt

3/5/03

H. Jey Tsai

Primary Examiner
Patent Examining Group 2800